



Docket No.: M4065.0319/P319
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Ronald A. Weimer, et al.

Application No.: 09/296,835

Group Art Unit: 2813

Filed: April 22, 1999

Examiner: E. Kielin

For: FABRICATION OF DRAM AND OTHER
SEMICONDUCTOR DEVICES WITH AN
INSULATING FILM USING A WET RAPID
THERMAL OXIDATION PROCESS

RESPONSE TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents
Washington, DC 20231

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Dear Sir:

TECHNOLOGY CENTER 2800

In response to the Election of Species Requirement set forth by the Examiner in the Office Action mailed September 27, 2000, Applicants hereby provisionally elect the species of Group I, covered by claims 1-12, drawn to a method of forming an oxide layer, for continued examination, without traverse.

Applicants' election is made without prejudice. As noted by the Examiner, upon the allowance of a generic claim, Applicants will be entitled to consideration of claims drawn to a reasonable number of non-elected species in addition to the elected species, provided that all claims to each additional species are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.146.

An action on the merits of all the claims and a Notice of Allowance thereof are respectfully requested.

Dated: November 6, 2000

Respectfully submitted,

By 

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